



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **WATANABE, Kenichi**

Serial No.: **09/987,012**

Filed: **November 13, 2001**

Group Art Unit: **2815**

Examiner: **Chris C. Chu**

P.T.O. Confirmation No.: **6363**

For. **SEMICONDUCTOR WAFER DEVICE HAVING SEPARATED CONDUCTIVE PATTERNS IN PERIPHERAL AREA AND ITS MANUFACTURING METHOD**

REQUEST FOR APPROVAL OF DRAWING CHANGES

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

May 15, 2003

Sir:

The Examiner's approval of the drawing corrections indicated in red ink on the attached four (4) sheets of drawings is respectfully requested.

Upon receipt of approval of the drawing corrections and a formal Notice of Allowance, a bonded draftsman will be retained and the appropriate corrections will be made.

In the event any fees are required in connection with this paper, please charge our Deposit Account No. 01-2340.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

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James E. Armstrong IV  
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Reg. No. 42,266

JAM/kas  
Atty. Docket No. **011264**  
Suite 1000  
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Washington, D.C. 20006  
(202) 659-2930



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PATENT TRADEMARK OFFICE

Attachment: 4 Sheets of Corrected Drawings

RECEIVED  
MAY 20 2003  
TECHNOLOGY CENTER 2200

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do not enter  
C.C.  
7/23/03*

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J.M. Minniman  
5/22/03*